

Title (en)

METHOD FOR FORMING A PRIMING LAYER FOR DEPOSITING A METAL ON A SUBSTRATE

Title (de)

VERFAHREN ZUM BILDEN EINER VORBEREITUNGSSCHICHT ZUM ABSCHEIDEN EINES METALLS AUF EINEM SUBSTRAT

Title (fr)

PROCEDE DE FORMATION D'UNE COUCHE D'AMORCAGE DE DEPOT D'UN METAL SUR UN SUBSTRAT

Publication

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Application

EP 09729442 A 20090330

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Abstract (en)

[origin: WO2009125143A2] The invention relates to a method for forming, on a substrate (5), a priming layer enabling a subsequent deposit of a layer of a metal, which comprises immersing the substrate in a bath (7) including a material in the ethoxysilanes or siloxanes families and a copper or nickel amidinate.

IPC 8 full level

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Citation (search report)

See references of WO 2009125143A2

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